

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

**Mark D. Owen, Bonnie A. Larson,
and Jozef Van Puymbroeck**

Application No. 08/651,036

Filed: May 17, 1996

For: **METHOD EMPLOYING UV LASER PULSES OF VARIED
ENERGY DENSITY TO FORM DEPTHWISE SELF-LIMITING
BLIND VIAS IN MULTILAYERED TARGETS**

Date: May 29, 1998

Examiner: Gregory Mills

SUPPLEMENTAL AMENDMENT

**TO THE ASSISTANT
COMMISSIONER FOR PATENTS:**

Following applicants' May 1, 1998 response to the April 3, 1998 Office action, please additionally amend the above-identified patent application as follows.

In the Drawings:

Add Figs. 23 and 24.

In the Specification:

On page 8, line 16, after "invention.", add the following paragraph:

--Fig. 23 presents a table of Example 12 of parameters of laser pulses employed to produce through-hole vias and blind vias; the blind vias were produced by processing the organic dielectric and the metal layers at different peak powers.

Fig. 24 presents a second table of Example 12, showing the conversion of the original data into fluences and power densities by well-known laser equations.

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On page 20, line 8, after "possible.", add the following paragraphs:

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